

Application to Use UTA NanoFAB Facilities (INTERNAL)

Internal form only for Academic Users from UTA to request training and access to NanoFAB Facilities

Name of the User (Student or Post-Doctoral Associate):

UT-ID #: _____

E-Mail address: _____

Tel No: _____

Residence Address:

Name of Project:

Please provide a short description of the project outlining how the NanoFAB facilities will be utilized by the person named above:

Please indicate where to charge usage fees (see attached fee structure):

Sponsored Grant / Contract

Acct #: _____, Sponsor: _____

Maximum Amount Authorized: _____

PI Name: _____, PI Signature: _____

Is this a NanoFab Project? Yes No

Application to Use UTA NanoFAB Facilities (INTERNAL)

Internal form only for Academic Users from UTA to request training and access to NanoFAB Facilities

IDC Acct #: _____,
Maximum Amount Authorized: _____
Account Holder's Name: _____, Signature: _____

Other Account #: _____, Maximum Amount Authorized: _____
Authorizing Person: _____, Signature: _____

Please indicate if the graduate student is registered under your section for a research, thesis or a dissertation course. Please note: only the primary advisor, for whom the student registers under, can request NanoFab access. For the student to continue using the NanoFab facilities, s/he has to remain a graduate student under the supervision of the same faculty.

Please notify the NanoFab administration if the status changes.

Yes, Course name and Number:

No.

User:

I certify that I am a full-time graduate student under the supervision of a UTA Graduate Faculty. I agree to abide by the NanoFAB Safety and Operating Procedures. I understand that such access can be revoked by the NanoFAB Director or Manager in the event these procedures are violated.

User Name

Signature

Date

Faculty:

I certify that I am a UTA Graduate Faculty supervising the graduate student or post-doctoral associate named above on the project summarized in this form.

I understand that such access can be revoked by the NanoFAB Director or Manager in the event the person fails to follow NanoFAB rules and procedures.

Graduate Faculty Advisor

Signature

Date

Approved: _____
Director of NanoFAB

Date

Application to Use UTA NanoFAB Facilities (INTERNAL)

Internal form only for Academic Users from UTA to request training and access to NanoFAB Facilities

USAGE FEE SCHEDULE FOR ACADEMIC USERS FROM UTA

All hourly fees are per person (student, post-doc). Minimum time unit is 1 hr.

All supplies and consumables are to be provided (subject to the approval of the NanoFab management) by the user except for those provided by NanoFab. Consumables specific to equipment might have to be purchased from NanoFab. A list of consumables provided free of charge and those to be purchased from NanoFab is provided upon request.

<i>Equipment / Service</i>	<i>New User fee</i>	<i>Usage, Assisted Usage, Training (Prior on-site training required) /hr</i>	<i>Maximum per quarter per faculty</i>	<i>Policy for maximum fee</i>	
Monthly Access Fee		None			
General Lithography / Patterning	None	\$50	\$1,000	can be combined with usage of other common equipment in NanoFab towards max. fee of \$1,500/quarter/group.	
General Wet Chemistry	None	\$50			
RF / DC Sputtering	None	\$50			
Thermal Evaporation	None	\$50			
PLD / Laser Annealing	None	\$50			
E-Beam Evaporation	None	\$50			
PECVD	None	\$50			
DRIE	None	\$50			
RIE (III-V)	None	\$50			
AFM	None	\$50			
RTA	None	\$50			
Dicing Saw	None	\$50			
E-Beam Writer*	\$450	\$80			\$1,000
FIB *		\$80			\$1,000
SEM / EDAX*		\$50	\$1,000		
Safety Training (required)	None	free	-	-	
NanoFab Tours / Usage Assessment	None	free	-	-	